

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

IN RE APPLICATION OF: Anisul Khan et al.

SERIAL NO.: Not yet assigned

FILED: December 18, 2000

FOR: APPARATUS FOR PERFORMING  
SELF CLEANING METHOD OF FORMING  
DEEP TRENCHES IN SILICON SUBSTRATES

§ GROUP ART UNIT: Unknown

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§ EXAMINER: Unknown

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§ Attorney Docket No.:

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AM-3396.D1

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Date: December 18, 2000

**PRELIMINARY AMENDMENT "A"**

Hon. Commissioner for Patents  
Washington, DC 20231

Sir:

This Preliminary Amendment "A" accompanies a divisional application of U.S. Application  
Serial No. 09/405,349, filed September 24, 1999.

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**CERTIFICATE OF MAILING UNDER 37 CFR 1.10**

I hereby certify that this paper is being deposited with the U.S. Postal Service on the date shown below  
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Date: December 18, 2000

  
Shirley L. Church, Reg. No. 31,858